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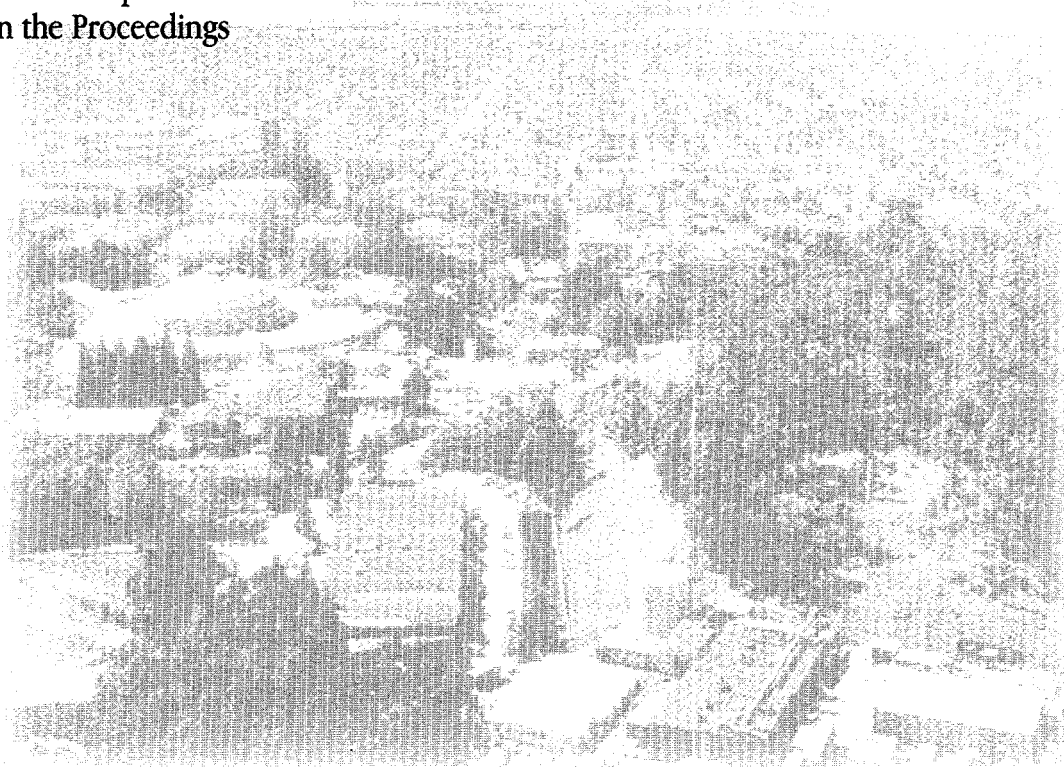
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Sol-Gel Deposited Electrochromic Coatings

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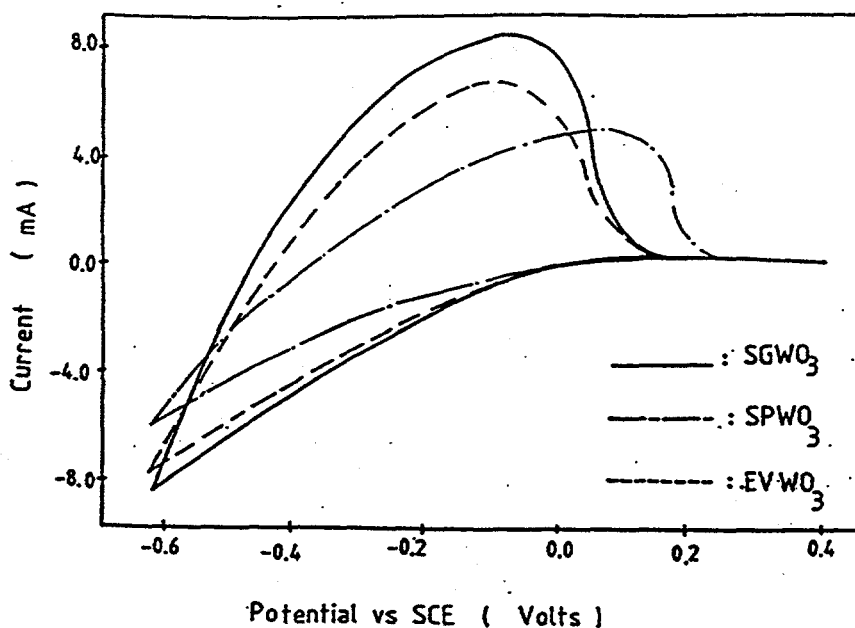
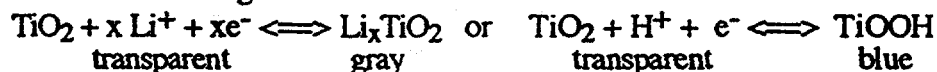


Fig. 1. Cyclic voltammograms of WO_3 films. $0.1 \text{ H}_2\text{SO}_4$ solution was used as an electrolyte with a sweep rate of 20 mV/s . The film thicknesses were about 200 nm for each film. The films color under a negative potential.

2.2. Titanium Oxide

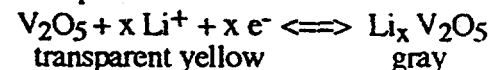
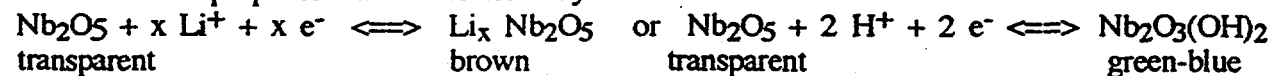
Sol-gel titanium oxide films can be formed from the classical alkoxy route and by the colloidal route [6,9,14]. They appear to be amorphous by X-ray diffraction. Upon heating the films crystallized into TiO_2 anatase around $400 \text{ }^\circ\text{C}$. Amorphous TiO_2 undergoes an electrochromic reactions according to :



Titanium oxide also colors when reduced by ion insertion, but its coloration efficiency is lower than tungsten oxide. Amorphous films change from transparent to gray or blue when reduced by Li^+ or H^+ ions.

2.2. Niobium and Vanadium Oxides

The group V-B oxides, namely Nb_2O_5 and V_2O_5 exhibit cathodic electrochromism like WO_3 . Although the change in optical spectrum between oxidized and reduced state by ion intercalation is not as large WO_3 , it has been shown that these oxides have good Li^+ ion storage capability and reversibility [2,6,15]. The reversibility of V_2O_5 in the crystalline state is superior to that in the amorphous state. Sol-gel niobium and vanadium oxide films have been synthesized from alkoxides, oxoalkoxides or alkoxyhalides based solutions [15-17]. XPS and optical spectra of the colored V_2O_5 and Nb_2O_5 coatings together with electrochemical experiments show that the electrochromic properties can be described by:

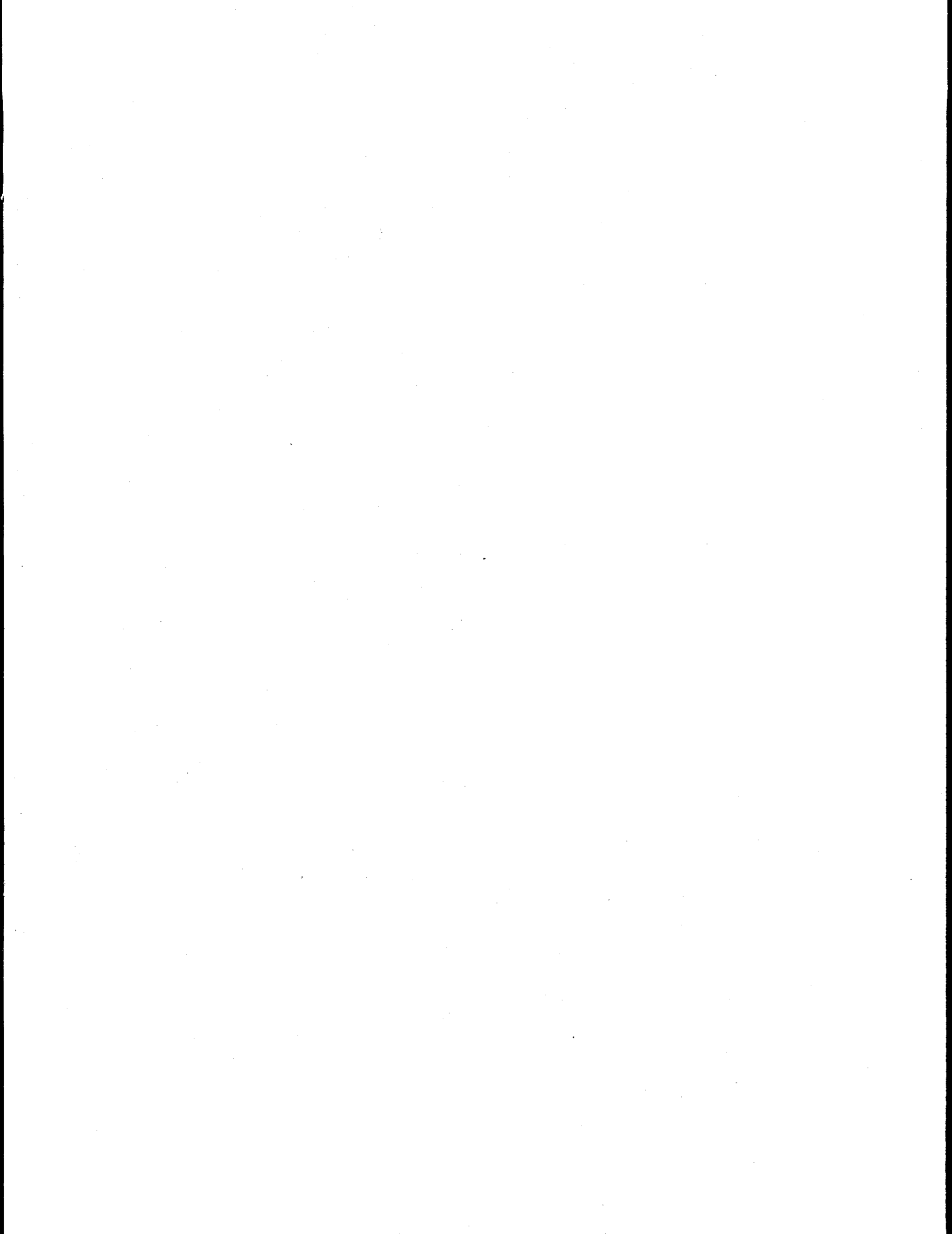


2.4. Nickel Oxide

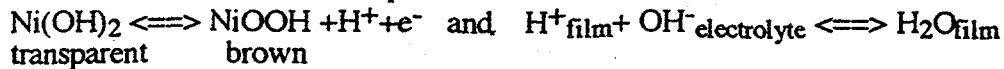
Nickel oxide is presently the subject of several studies [2,17]. Nickel oxide films have been formed by dissolving or reacting nickel nitrates in alcohol and then using the product as precursors [18]. The coloration mechanism has been determined for protons by J. C. Giron [19].

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The reaction involves two coupled reactions:



Sol-gel films made from nickel methoxyethoxide precursor also showed a transparent to brown electrochromism with Li^+ insertion. These films colored by anodic transfer of electrons out of the film couple with anion injection from the electrolyte.

Table 1. summarizes some properties of the sol-gel deposited electrochromic layers.

Table 1. Sol-gel electrochromic coatings

Material	Color neutral	oxidized or reduced form	Stability (lifetime)	Electrode	Reference
WO_3 (C)	Transparent	Blue	10^4 cycles	LiClO_4	11-13
TiO_2 (C)	Transparent	Gray or blue	10^3 cycles	LiClO_4	6, 14
Nb_2O_5 (C)	Transparent	Brown, gray	10^4 cycles	LiClO_4	1, 15
V_2O_5 (A)	Light yellow	Brown, green	10^3 cycles	LiClO_4	1, 6
NiO_x (A)	Light green	Brown	10^3 cycles	LiClO_4	present work

note: (C) cathodically coloring, (A) anodically coloring.

2.5. Sol-gel made devices

The construction of display devices or smart windows consist of typically a (1) transparent conductor (ITO), (2) electrochromic layer, (3) solid electrolyte or ion conductor, (4) ion storage layer, (5) transparent conductor. Recently, the sol-gel process has been also adopted to prepare a variety of inorganic type solid electrolytes [20, 21]. An all sol-gel electrochromic device has been realized using sol-gel coatings with the configuration glass /ITO / WO_3 / TiO_2 / $\text{TiO}_2\text{-CeO}_2$ /ITO /glass [22]. The optical transmission spectra of these window is shown in fig. 2. This window has a fast optical response, but a short lifetime. Currently, several groups are trying to develop devices using some or all sol-gel deposited layers.

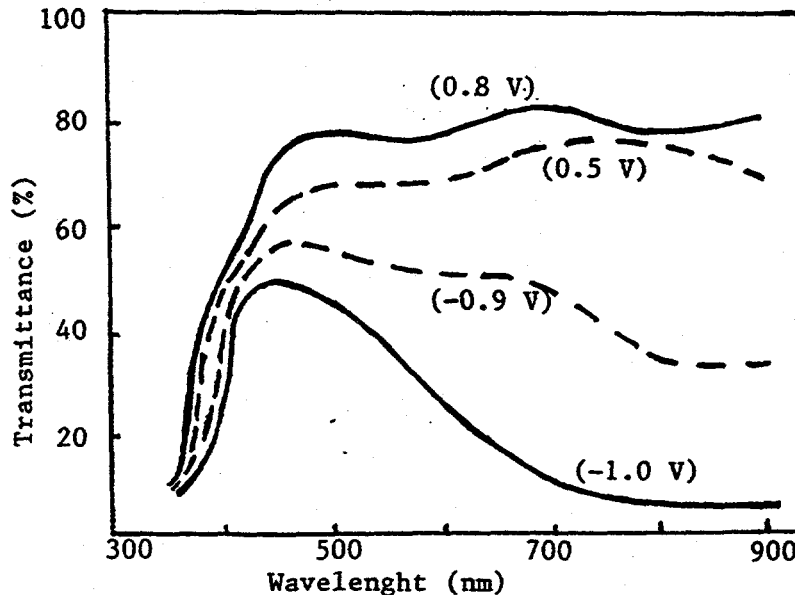


Fig. 2. Optical transmission of two electrochromic windows having the configuration : glass /ITO / H_xWO_3 / $\text{TiO}_2\text{-sg}$ / $\text{CeO}_2\text{-TiO}_2\text{-sg}$ / ITO / glass, where (—) is vacuum evaporated WO_3 and (---) is a sol-gel (sg) WO_3 .

4. SUMMARY

The sol-gel process offers new approaches for the fabrication of electrochromic materials. In the electrochromic device construction, microstructure control and chemical composition of the layers are important since they need to have electron and ion transport properties in addition to the optical requirements. Major advantages of the sol-gel process are ease of stoichiometry control and low sintering temperatures. Large-area coating can be easily deposited under ambient conditions by dip coating, spin coating, spraying or even screen printing. Sol-gel deposited electrochromic layers have similar properties to those films deposited by vacuum techniques. We expect to see further developments in sol-gel deposited films for electrochromic devices in the future.

5. ACKNOWLEDGMENT

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